
Company Introduction

We design the dream of leading the digital powerhouse Korea,
the future of the Korean equipment industry.

Securing equipment proprietary technology
through endless R&D, and
taking a bold leap forward to become
the world's best equipment company.

These are Wonik IPS's goals and biggest values.

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*We design the dream of leading the digital powerhouse Korea,
the future of the Korean equipment industry.*

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We design the dream of leading
the digital powerhouse Korea,
**the future of the Korean
equipment industry.**

Company Name	WONIK IPS
CEO	Taehyuk Ahn
Established Date	September 19, 1991
Address	75, Jinwisandan-ro, Jinwi-myeon, Pyeongtaek-si, Gyeonggi-do
Employees	1,472 (as of October 31, 2025)
Main Business	Core equipment for front-end processes of semiconductor and display
Capital	24.5 billion won (Total number of issued shares : 49,083,901 shares)
Listed Date	September 24, 1996 (KOSDAQ)
Website	www.ips.co.kr

CEO

Employees : 1,472 (as of October 31, 2025)

Semiconductor

(967)

Research Institute

Advance Development HQ

T/F Development HQ

Diff. Development HQ

SEC Sales

SKH Sales

GMS

Display

(227)

Business Management

Research Institute

Display Sales HQ

Staff

(89)

Management Support Office

PI HQ

HR HQ

(188)

SCM

At the beginning of localizing semiconductor equipment, you can find WONIK IPS.

We aim to reinvent ourselves as a global equipment maker to better serve the world.

1999~2010

- 2010.12 ATTO and IPS merged
- 2006.11 Split off the special gas business division
: WONIK Materials
- 2005.10 IPS acquired ATTO
- 1999.01 IPS was incorporated as an affiliate of WONIK

2011~2015

- 2014.01 13.15% share of Tera Semicon acquired
(listed as the largest shareholder)
- 2012.06 Dunpo Campus completed
- 2011.03 Change of company name : WONIK IPS

2016~

- 2019.02 WONIK IPS and Tera Semicon merged
- 2016.07 The largest shareholder changed
(from WONIK to WONIK Holdings)
- 2016.05 Re-listed on KOSDAQ
- 2016.04 Spun-off the company
: WONIK Holdings, surviving company ;
WONIK IPS, new company

2021~

- 2022.06 Jinwi 3rd Industrial Complex completed

We contribute to human development by providing creative technologies and services in a fair and transparent manner



Freedom

Break away from stereotypes or customs, come up with a unique way through open thinking, and take responsibility and perform on our own way



Communication

Ensure that members move toward one direction by understanding each other's position with a sincere heart and sharing each other's experience, knowledge and information based on rational expression



Happiness

Create a pleasant workplace based on trust with all members taking pride in being 'WONIK People', and feel a sense of accomplishment and reward through work

Domestic 5 business sites, 4 CS sites

Overseas 5 corporations, 1 branch, 1 CS site

Jinwi Campus (HQ)

Semiconductor Clean Room and R&D Lab
 - Class 10 Level
 - Operation of Parts Development Lab
 Semiconductor Sales/STAFF

Giheung Site

Semiconductor Thin film Development
 Software /STAFF

Jinwi 3rd Industrial Complex

Semiconductor Integrated Manufacturing Center
 Operation of Training Center
 Capacity : T/F 85 System / Month
 Diff. 26 System / Month

Icheon Site

Semiconductor SKH Sales / CS Center

Dunpo Site

Display Business HQ
 Display Manufacturing Center
 - Capacity : 80 Chamber / Month



CS Site Pyeongtaek / Hwaseong / Cheongju / Cheonan

Overseas

U S	Texas / New York (site)
China	Xian / Wuxi / Kunshan
Singapore	Woodland
Taiwan	Xinzhu (branch)

Our key products include semiconductor, LCD and AMOLED,
and **we are growing as a integrated equipment manufacturer on a global scale**
by diversifying our businesses **through ongoing R&D.**

WONIK IPS Business Portfolio

Semiconductor

Deposition

GEMIPRO™ (CVD/ALD)

NOA™ (CVD/ALD)

HyEta™ (ALD)

CUARTO VS™ (CVD)

LEVATA-CP™ (CVD)

CLARO™ (ALD)

PRESTO™ (ALD)

VELOCE™ (ALD)

Thermal System

300SERIES™

MODUS™

Display

Deposition

BP PECVD

TFE PECVD

Etching

ICP Dry Etcher

CCP Dry Etcher

Laser Etcher

Laser Driller

Thermal System

PI Cure

LT/IGZO Furnace

GEMIPRO™

Application process : DRAM / NAND / Logic
 Dielectric CVD / ALD
 Process : SiON / a-Si / SiO₂ (@TEOS, SiH₄)
 ALD OX / SiN / SiOC / SiCN

Core technologies

1. High Temp. Extreme stability
2. Wafer centering technology
3. Auto level system

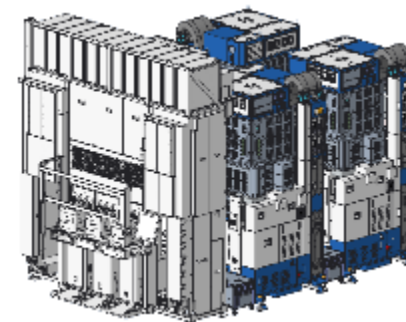


CUARTO VS™

Application process : NAND
 Dielectric CVD
 Process : ON-Stack, High Thick TEOS,
 Seem free Oxide

Core technologies

1. High Throughput, compact layout
2. Minimize dead volume, mini block
3. ESC & IMS
4. Extreme stress control



NOA™

Application process : DRAM / NAND
 Dielectric CVD, ALD
 Process : Ti / TiN / W

Core technologies

1. Large capacity, flow rate system
2. Horizontal monitoring system (Stage heater)



HyEta™

Application process : DRAM / NAND
 Dielectric ALD
 Process : SiO₂ Seamless Gap Fill / ZrO₂ / AlO

Core technologies

1. Gas balance control technology
2. Dual pumping structure



300SERIES™

Application process : DRAM / NAND

Dielectric CVD

Process : Oxidation / Anneal / Alloy / PI bake Poly / ALD Ox/SiN



Core technologies

1. High productivity, small footprint
2. Advanced heater temp. control

LEVATA-CP™

Application process : DRAM / NAND

Dielectric CVD

Process : Poly



Core technologies

1. High productivity, small footprint
2. Excellent thickness uniformity
3. Complete load lock control

Dry Etcher

ICP Type Antenna
Process : OLED / a-Si / Oxide

Core technologies

1. High etch rate & throughput
2. Long term PM cycle
3. Easy maintenance

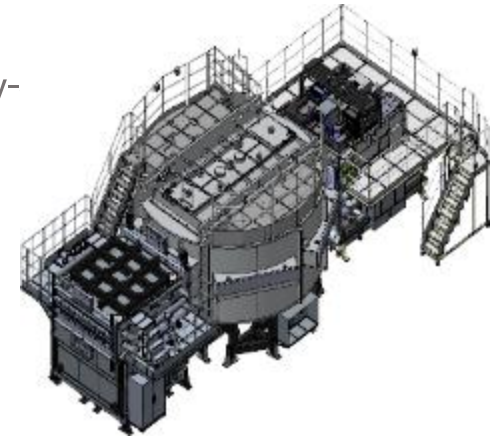


BP PECVD

High Temp. Process
Process : SiNx / SiOx / a-Si / Poly-

Core technologies

1. Low damage plasma mode
2. High quality film uniformity
3. Muti zone & Bias susceptor



Dry Etcher

CCP Type
Process : LCD & OLED / a-Si / Oxide

Core technologies

1. High etch rate & throughput
2. Unique arc management
3. Advanced particle management

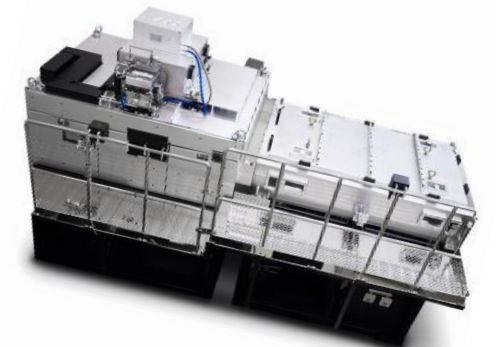


TFE PECVD

Low Temp. Process
Process : SiON / SiNx / SiO2

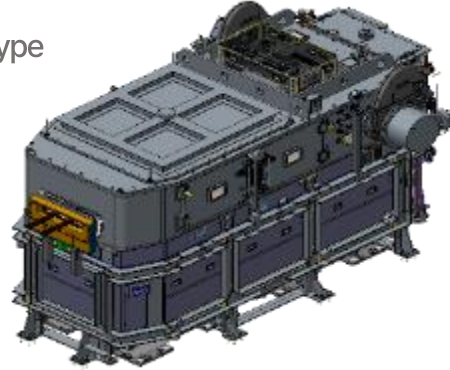
Core technologies

1. Low damage plasma mode
2. High quality film uniformity
3. Controllable film stress



Laser Etcher

Bottom-Up / Top-Down process type
Process : EV In-line etch by laser



Core technologies

1. High precision hole etch
2. High precision moving stage
3. High vacuum process

PI Cure

Flexible OLED TFT Backplane
Process : PI Film Cure

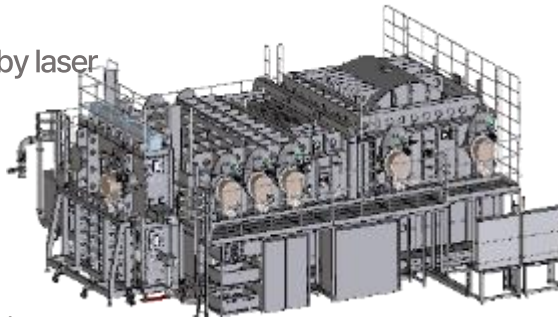


Core technologies

1. Fast ramping process
2. Uniform laminar flow control
3. Structure for particle suppression

Laser Driller

Bottom-Up process type
Process : EV In-line drilling by laser



Core technologies

1. High precision Drilling
2. Flip & High precision moving stage
3. High vacuum process

LT Furnace

Rigid & Flexible Backplane
Process : Contact Anneal, Activation

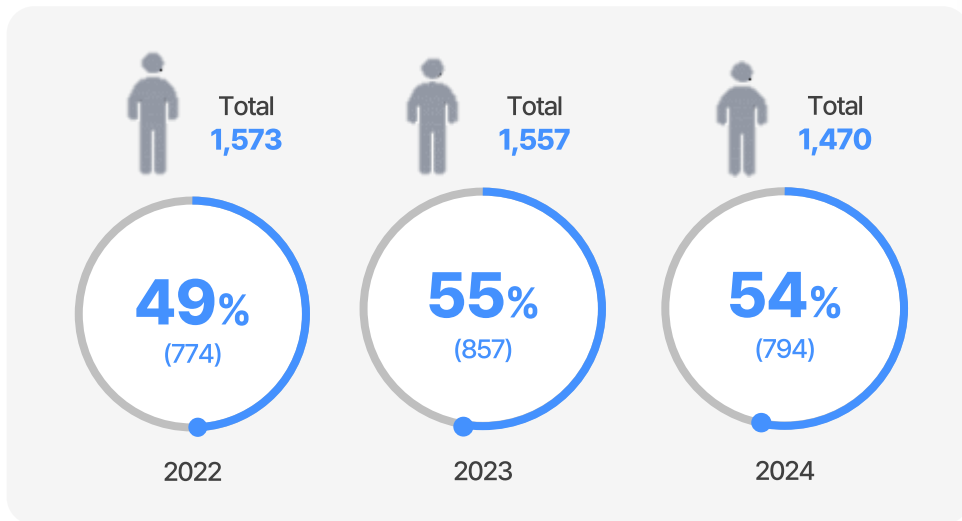


Core technologies

1. Excellent temp. uniformity
2. High productivity (Fast ramp up/down)
3. Perfect sealing for O2 density control

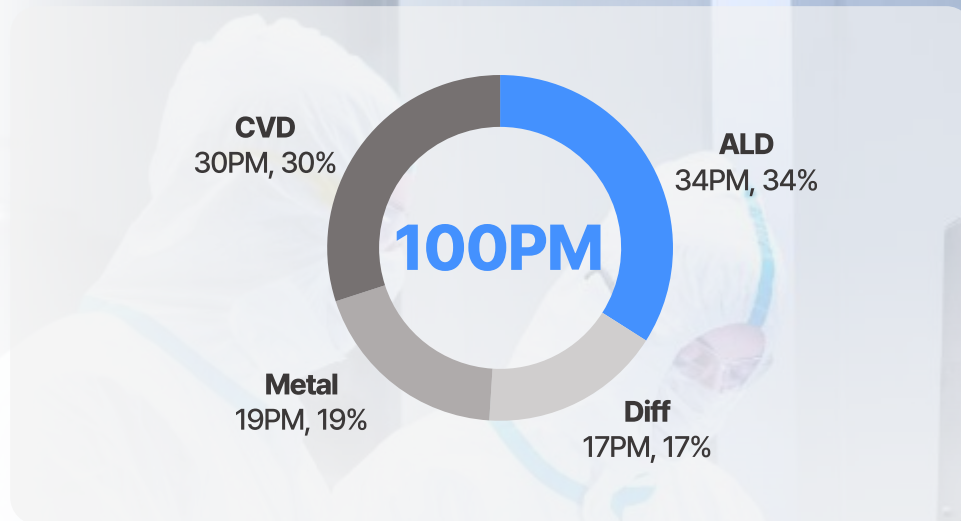
Human Resource

: Status of R&D Manpower



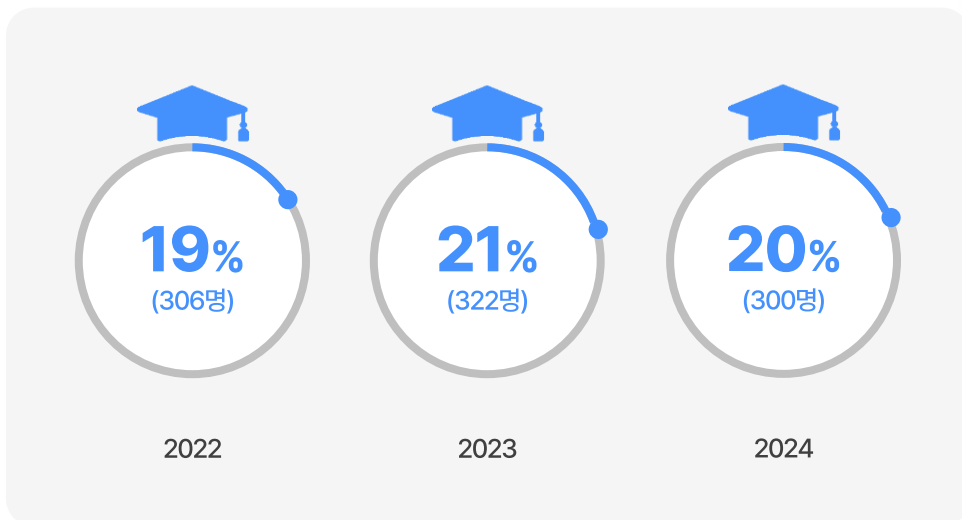
R&D equipment status

: Semiconductor (43PM on 2nd floor, 51PM on 3rd floor, 6PM R&D 2nd Fab)



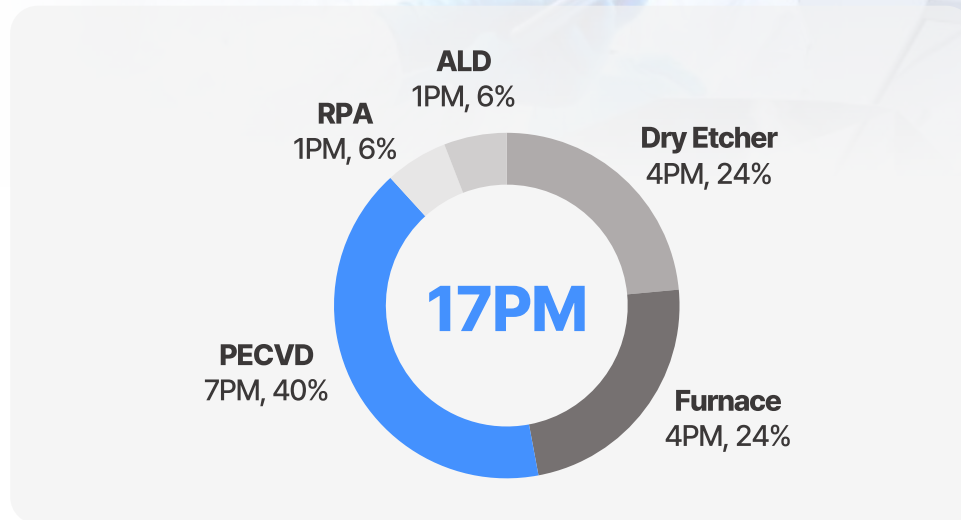
Human Resource

: Status of Manpower with Master's Degree and Doctoral Degree



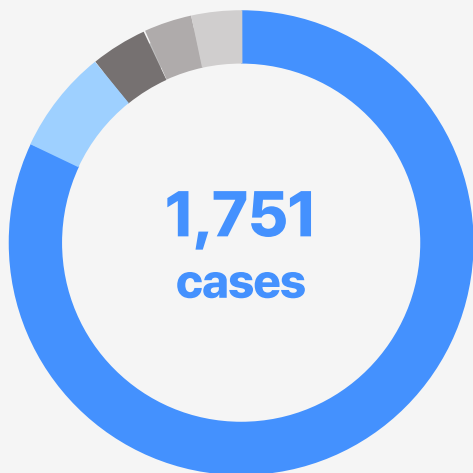
R&D facility status

: Display (Jinwi 11PM, Dunpo 4PM, SDC 2PM)



* as of December 31, 2024

Patent application status (including utility model)



Korea 1395 cases, **79%**
China 133 cases, **8%**
Taiwan 100 cases, **6%**
US 66 cases, **4%**
Japan 57 cases, **3%**

(Unit : Number of cases)

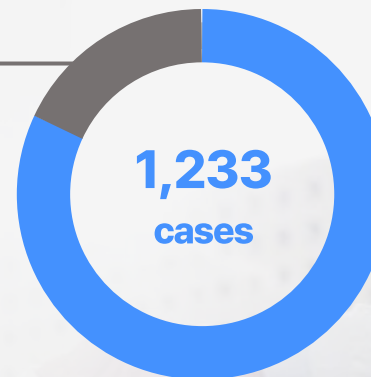
	Korea	China	Taiwan	US	Japan	Total
Application	760	64	33	30	12	899
Registration	635	69	67	36	45	852
Total	1,395	133	100	66	57	1,751

* as of December 31, 2024

Patent application status by business field

Semiconductor (Total 1,233 cases)

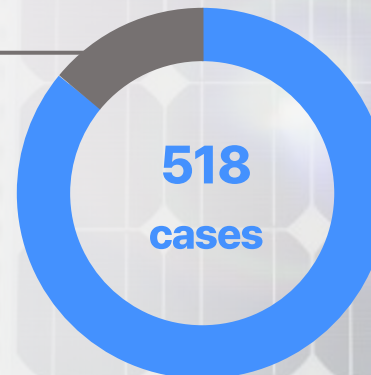
Overseas
273 cases,
22%



Domestic
960 cases,
78%

Display (Total 518 cases)

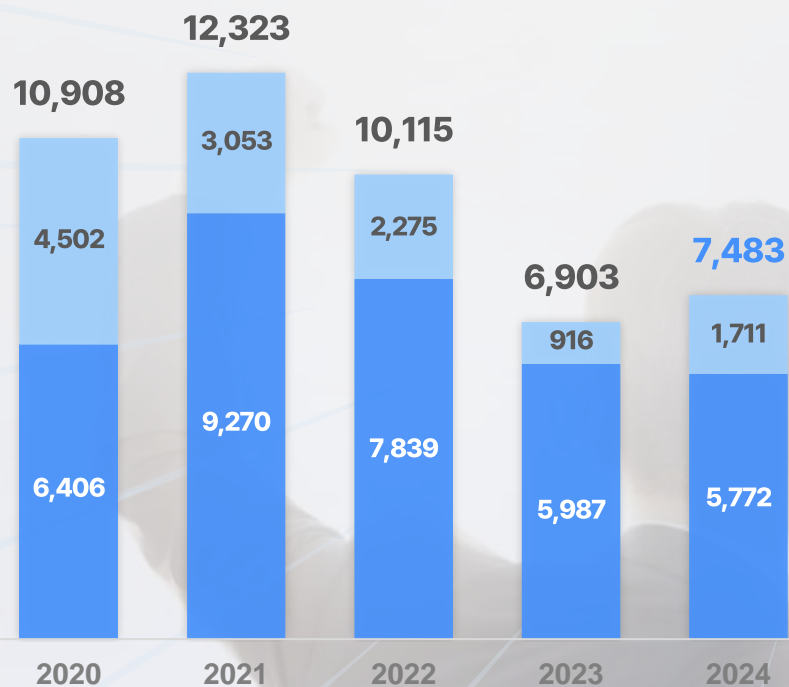
Overseas
83 cases,
16%



Domestic
435 cases,
84%

5-year Sales Trend

(Unit: 100 million KRW)


 ■ Semiconductor ■ Display


* Separate financial statements

5-year Financial Position

(Unit: 100 million KRW)

	2020	2021	2022	2023	2024
Total Assets	11,006	11,655	11,202	10,831	11,228
Current Assets	6,561	6,735	5,936	5,840	6,407
Non-Current Assets	4,445	4,920	5,267	4,992	4,821
Total Liabilities	4,378	3,683	2,533	2,190	2,378
Current Liabilities	4,311	3,611	2,503	2,104	2,302
Non-Current Liabilities	68	71	30	86	76
Total Equity	6,628	7,972	8,669	8,641	8,850
Capital Stock	245	245	245	245	245
Current Ratio	152%	187%	237%	278%	278%
Liabilities to -Equity Ratio	66%	46%	29%	25%	27%
Debt to Equity Ratio	-	-	-	-	-

ESG

Environment

Create eco-friendly corporate culture through achieving the high level of environmental safety systems

- Establish and monitor hazardous chemical management processes
- Response actively to climate change through energy consumption and greenhouse gas emission management
- Conduct education, inspection and emergency response training
- Reinforce the safety inspections and measurements of working environment to prevent any environmental safety accidents

Social

Ethical management practice through the declaration of compliance management and social contribution activities

- Implement human rights strengthening activities such as humanitarian treatment and prohibition of discrimination
- Selected as 'Best Jobs Company' for 3 consecutive years by contributing to the creation of youth employment and new jobs
- Realize a good company to work for through establishing flexible organizational culture and welfare policy

Governance

Transparent / fair business operation

- Operation of independent and transparent board and audit committee
- Information disclosure and IR activities for shareholders and investors
- Operation of the reporting site, distribution of business guidelines for business partners, etc.

Shared Growth

Reinforcement of innovation capacity

- Performance of consulting and operating training / support programs to strengthen partner company's quality capabilities
- Conducting mutual technology innovation activities through quality exchange meetings

Shared growth index evaluation

- Participation in the shared growth comprehensive evaluation of the Korean Commissions for corporate partnership
- Implementation evaluation of the Fair Trade Agreement by the Fair Trade Commission



Open communication

- Rewarding excellent partners and holding regular exchange meetings
- Operation of the Autonomous Council of Major Partners (Wonwu Association)
- Opening of subcontract VOC windows

Win-win cooperation

- Pursuing shared growth through free equipment rental, technical support, and joint development
- Paying twice a month and operating win-win payment system

Major Affiliates

Semiconductor	Secondary Battery	Trade	Others

Sales Trend

(Unit: 100 million KRW)

